IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Original): A method for adjoining at least two protective barriers on a processing element comprising:

defining a transition region on said processing element, wherein said transition region comprises an overlap of a first protective barrier and a second protective barrier;

applying said first protective barrier to a first region of said processing element, said first region comprising said transition region;

treating a second region of said processing element in order to improve adhesion of said second protective barrier, said second region comprising said transition region; and applying said second protective barrier to said second region.

Claim 2 (Original): The method as recited in claim 1, wherein said transition region comprises at least a portion of an edge.

Claim 3 (Original): The method as recited in claim 2, wherein said edge is characterized by at least one edge radius.

Claim 4 (Original): The method as recited in claim 3 further comprising forming said edge, wherein said edge comprises one edge radius, and said edge radius ranges from 0.5 mm to 5 mm.

Claim 5 (Original): The method as recited in claim 4, wherein said edge radius ranges from 0.5 mm to 2 mm.

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Claim 6 (Original): The method as recited in claim 1, wherein said first protective layer and said second protective layer comprise at least one of a surface anodization, a coating formed using plasma electrolytic oxidation, and a spray coating.

Claim 7 (Original): The method as recited in claim 1, wherein said first protective layer and said second protective layer comprise at least one of alumina, carbon, silicon carbide, silicon, quartz, Teflon, Vespel, and Kapton.

Claim 8 (Original): The method as recited in claim 1, wherein said first protective barrier and said second protective barrier comprise at least one of a III-column element and a Lanthanon element.

Claim 9 (Currently Amended): The method as recited in claim 1, wherein said first protective barrier and said second protective barrier comprise at least one of Yttria (Y₂O₃), Sc₂O₃, Sc₂F₃, YF₃, La₂O₃, CeO₂, Eu₂O₃, and [[Dy03]] <u>Dy₂O₃</u>.

Claim 10 (Original): The method as recited in claim 1, wherein said first protective barrier comprises a surface anodization, and said second protective barrier comprises a spray coating.

Claim 11 (Original): The method as recited in claim 1, wherein said treating comprises grit blasting.

Claim 12 (Original): A processing element for a processing system comprising: a first protective barrier coupled to a first region on said processing element; and a second protective barrier coupled to a second region on said processing element, wherein said first region and said second region overlap to form a transition region.

Claim 13 (Original): The processing element as recited in claim 12, wherein said second region is treated to improve the adhesion of said second protective barrier.

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Claim 14 (Original): The processing element as recited in claim 13, wherein said treating comprises grit blasting.

Claim 15 (Original): The processing element as recited in claim 12, wherein said transition region comprises at least a portion of an edge.

Claim 16 (Original): The processing element as recited in claim 15, wherein said edge is characterized by at least one edge radius.

Claim 17 (Original): The processing element as recited in claim 16, wherein said edge comprises one edge radius, and said edge radius ranges from 0.5 mm to 5 mm.

Claim 18 (Original): The processing element as recited in claim 17, wherein said edge radius ranges from 0.5 mm to 2 mm.

Claim 19 (Original): The processing element as recited in claim 12, wherein said first protective layer and said second protective layer comprise at least one of a surface anodization, a coating formed using plasma electrolytic oxidation, and a spray coating.

Claim 20 (Original): The processing element as recited in claim 12, wherein said first protective layer and said second protective layer comprise at least one of alumina, carbon, silicon carbide, silicon, quartz, Teflon, Vespel, and Kapton.

Claim 21 (Original): The processing element as recited in claim 12, wherein said first protective barrier and said second protective barrier comprise at least one of a III-column element and a Lanthanon element.

Claim 22 (Currently Amended): The processing element as recited in claim 12, wherein said first protective barrier and said second protective barrier comprise at least one of Yttria (Y₂O₃), Sc₂O₃, Sc₂F₃, YF₃, La₂O₃, CeO₂, Eu₂O₃, and DyO₃ <u>Dy₂O₃</u>.

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Claim 23 (Original): The processing element as recited in claim 12, wherein said first protective barrier comprises a surface anodization, and said second protective barrier comprises a spray coating.

Claim 24 (Original): The processing element as recited in claim 12, wherein the first and second protective barriers comprise the same material.

Claim 25 (Original): The processing element as recited in claim 12, wherein the first and second protective barriers comprise different materials.